



Docket No.: H0498.70130US01  
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

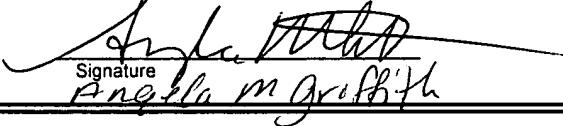
Applicants: Tao Deng et al.  
Serial No.: 10/763819  
Confirmation No.: 5026  
Filed: January 23, 2004  
For: FABRICATION OF METALLIC MICROSTRUCTURES VIA  
EXPOSURE OF PHOTORESISTIVE COMPOSITION  
Examiner: Kathleen Duda  
Art Unit: 1756

Certificate of Mailing Under 37 CFR 1.8(a)

I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being deposited with the U.S. Postal Service on the date shown below with sufficient postage as First Class Mail, in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Dated: April 28, 2006

Signature

  
Angela M. Griffith

**RESPONSE TO RESTRICTION REQUIREMENT**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed February 24, 2006, Applicants hereby provisionally elect claims Group III, claims 23-29 for continued examination, with traverse. The traversal was made on the grounds that it is believed that a single search and examination covering all claims would not place undue burden on the Examiner.

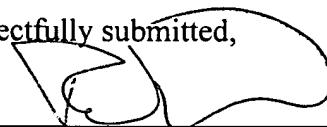
A first and favorable action is respectfully requested. If, for any reason, the Examiner is of the opinion that a telephone conversation with the Applicants' representative would expedite

prosecution, the Examiner is kindly invited to contact the undersigned at (617) 646-8000.

Dated: 4/24/06

Respectfully submitted,

By

  
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